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U.S. DEPARTMENT OF COMMERCE
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(Use several sheets if necessary)

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Yuzo MORI et al.FILING DATE
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GROUP 1742

U.S. PATENT DOCUMENTS

EXAMINER INITIAL		DOCUMENT NUMBER	DATE	NAME	CLASS	SUBCLASS	FILING DATE IF APPROPRIATE
NS	AA	6,368,493	4/2002	Mori et al.			
NS	AB	2002/0033343	3/2002	Mori et al.			
NS	AC	6,171,467	1/2001	Weihs et al.			

FOREIGN PATENT DOCUMENTS

		DOCUMENT NUMBER	DATE	COUNTRY	CLASS	SUBCLASS	TRANSLATION YES NO	
NS	AD	1139400	10/2001	Europe				
NS	AE	10-58236	3/1998	Japan				
NS	AF	2000-52235	2/2000	Japan				
NS	AG	00/34995	6/2000	WO				
NS	AH	1 079 003	2/2001	Europe				
NS	AI	2000-167714	6/2000	Japan				
	AJ	10-58236	3/1998	Japan				
	AK							

OTHER DOCUMENT(S) (Including Author, Title, Date, Pertinent Pages, Etc.)

NS	AL	Machine Translation of JP 2000-052235.
NS	AM	Patent Abstracts of Japan, vol. 013, no. 144 (E-740), April 10, 1989 & JP 63 306630 A (NEC CORP.), December 14, 1988, abstract.
NS	AN	Patent Abstracts of Japan, vol. 018, no. 658 (E-1643), December 13, 1994 & JP 06 260480 A (NEC CORP.), September 16, 1994, abstract.
NS	AO	Patent Abstracts of Japan, vol. 014, no. 227 (C-0718), May 15, 1990 & JP 02 054800 A (MITSUBISHI ELECTRIC CORP.), February 23, 1990, abstract.
NS	AP	Chen et al., "Selective etching of silicon in aqueous KOH", Materials Science & Engineering B34, (1995), pages 180-187.

EXAMINER

/Nicholas Smith/

DATE CONSIDERED

02/15/2007